

Performer Name/Institution (include partner institutions)

Institutio n Logo

Key Graphic(s) from Technical Volume

Replace this box with an image, diagram, or figure to aid in explaining your work.

Include concept description with bullets/text as necessary.

New Insights/Innovations:

- First key point.
- Additional key points as necessary.

Scientific/Technical Approach Summary:

Program Approach:

• Replace with text bullets and diagrams as necessary.

Assumptions, Risk & Mitigation:

- Describe assumptions of proposed approach, including criteria that will need to be met by partner challenge area projects (or by all for Thrust 2 proposers) and applicability of approach with respect to other deposition methods.
- Address risks of proposed approach, compatibility/requirements, and mitigation strategies.

Compatibility and Limitations:

Proposers to Thrust 1:

- List classes of thin films that should be applicable.
- List compatibility requirements (e.g., optical access, conductive substrate, need for vacuum environment, etc.).
- List required equipment (existing and proposed).

Proposers to Thrust 2:

• Describe compatibility requirements for part and LoCo process.

Budget:

\$